

SPECTROSCOPY OF RADIATION TRAPS IN Si BY TEMPERATURE DEPENDENT PHOTOCONDUCTIVITY AND GENERATION CURRENTS

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An analysis of excess carrier decay transients has been performed on the reactor neutron irradiated Si n-type material grown by the magnetic field applied Czochralski (MCZ) technology, using the microwave-probed photoconductivity (MW-PC) transient technique. The measurements of temperature dependent excess carrier lifetime variations were carried out on the just irradiated and annealed samples in order to identify the prevailing radiation defects and to predict trap behaviour under thermal treatments. The activation energy of the dominant carrier traps has been extracted. Barrier capacitance and generation current variations in neutron irradiated MCZ Si pin diodes have been controlled employing the barrier evaluation by the linearly increasing voltage (BELIV) technique, as well.

Keywords: spectroscopy of carrier traps, photoconductivity transients, carrier lifetime, generation current

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1. Introduction

Particle detectors based on Si pin structure are commonly employed in high energy particle experiments for rapid and reliable detection of high energy particles [1, 2]. However, large density of radiation induced defects acting as carrier traps affect the detector functional parameters by reducing the charge collection efficiency [1, 2], increasing the leakage current [1–3], and consequently modifying the pulsed transient waveforms [1–4]. This necessitates a deeper study of peculiarities of carrier recombination channels attributed to radiation defects of large density. Carrier thermal generation and trapping parameters are the most important in evaluation of the performance of particle detectors operating at high fluences. Therefore, new techniques are desirable for the reliable *ex situ* and *in situ* spectroscopy of large density traps when traditional methods, such as deep level transient spectroscopy (DLTS), become non-applicable. Determination of the spectral signatures (such as activation energy, capture cross-section, etc.) of the dominant radiation traps and of their variations during irradiation is important in order to clarify the main reasons of the degradation of particle detectors under heavy irradiations. This is also relevant in search of methods for the enhancement of radiation tolerance of particle detectors.

In this work, barrier capacitance, carrier recombination, generation and trapping parameters have been studied employing the barrier evaluation by linearly increasing voltage (BELIV) [5] and microwave probed photoconductivity transient (MW-PC) [6] techniques. A study of temperature dependent excess carrier lifetime variations has been carried out on the just irradiated and annealed samples in order to identify the prevailing radiation defects and to predict trap behaviour under thermal treatments. An analysis of temperature dependent generation current and carrier lifetime has been performed in order to evaluate activation energy of carrier recombination as well as trapping centres and to identify the dominant radiation defects. Spectroscopy and identification of the prevailing radiation defects is important to predict operational characteristics of the future detectors for high luminosity colliders.

2. Samples and measurement techniques

A set of n-type Si of high resistivity ($N_D \sim 10^{12} \text{ cm}^{-3}$) wafer samples grown by the magnetic field applied Czochralski (MCZ) technique and pin diodes [7] with an active area of $5 \times 5 \text{ mm}^2$ and thickness of $300 \mu\text{m}$, made of the same material, have been examined. These samples were irradiated with reactor neutrons of fluence Φ (1 MeV eq.) 10^{14} n/cm^2 . The surfaces of wafer

samples were passivated with thermal oxide. The isochronal anneals for 24 h were performed by varying heat treatment temperature in the range of 80–380 °C for wafer samples. Wafer samples were employed for analysis of carrier recombination and trapping/generation parameters, while diode samples were used to evaluate carrier generation characteristics.

Temperature dependent excess carrier decay transients have been examined by the MW-PC technique [6] modified by usage of the special cryostat. This cryostat has been designed for the precise positioning of the optical fibre-tip and needle-tip MW probes in vacuum. Also, this cryostat is supplied with the CaF window for additional bias illumination of a wide spectrum. The sample is commonly mounted on a cold finger cooled by liquid nitrogen. The liquid nitrogen flow is manipulated for precise temperature stabilization. Temperature control is performed on a cold finger and the sample. Excess carriers are photo-generated by 500 ps laser pulses of 1062 nm wavelength. The excitation light is transferred into the cryostat by using an optical fibre. The fibre-tip light spot excited area of the sample is probed by microwaves of 22 GHz using a needle-tip antenna. The microwave radiation is supplied to the needle-tip antenna by using the coaxial cables and vacuum proof connectors. The excess carrier decay transients are recorded by a 1 GHz digital *Tektronix* oscilloscope TDS-5104.

Barrier capacitance and generation current transient measurements are implemented by using the BELIV technique [5, 8]. The BELIV measurement circuit consists of a sample which is connected in a series with a 50 Ω load resistor and a generator of linearly increasing voltage (LIV). Transients are measured on a 50 Ω load resistor and recorded by the same 1 GHz digital oscilloscope TDS-5104. The temperature dependent BELIV pulsed transients are examined by mounting the sample on the cold finger of the liquid nitrogen cryostat supplied with special electrodes. The MW-PC and BELIV transients have been measured in the temperature range of 100–300 K.

The *in situ* measurements of barrier capacitance and generation current transients were performed at room temperature during irradiation by 25 MeV spallator-type neutrons at Louvain la Neuve University [9].

3. Experimental results and discussion

The creation of radiation defects was controlled by *in situ* measurements [4] of variations of the BELIV transients during irradiation by spallator neutrons. The evolution of BELIV transients is illustrated in Fig. 1(a). The transients for a reverse biased junction are composed of barrier capacitance charging $i_c(t)$ (as

the initial phase of the BELIV transient) and generation $i_g(t)$ (in the rearward stage of the transient) current components [5, 8]. These components and their sum are described as

$$i(t) = i_c(t) + i_g(t) = AC_{b0} \frac{1 + \frac{U_c(t)}{2U_{bi}}}{\left[1 + \frac{U_c(t)}{U_{bi}}\right]^{3/2}} + \frac{q_e n_i S w_0}{\tau_g} \left[1 + \frac{U_c(t)}{U_{bi}}\right]^{1/2}. \quad (1)$$

Here, $A = U_p/\tau_{PL}$ is the ramp of the LIV pulse with peak value U_p and duration τ_{PL} , U_{bi} is the built-in potential, $U_c(t) = At$ is the applied voltage which increases linearly with time, q_e denotes the elementary charge, n_i is the intrinsic carrier density, S is an area of the junction and $w_0 = (2\epsilon\epsilon_0 U_{bi}/q_e N_D)^{1/2}$ is the equilibrium depletion width dependent on dopant density N_D , ϵ and ϵ_0 are dielectric permittivity of the material and vacuum, respectively.

Variations of barrier capacitance and generation current as a function of neutron fluence are illustrated in Fig. 1(b). The value of barrier capacitance decreases

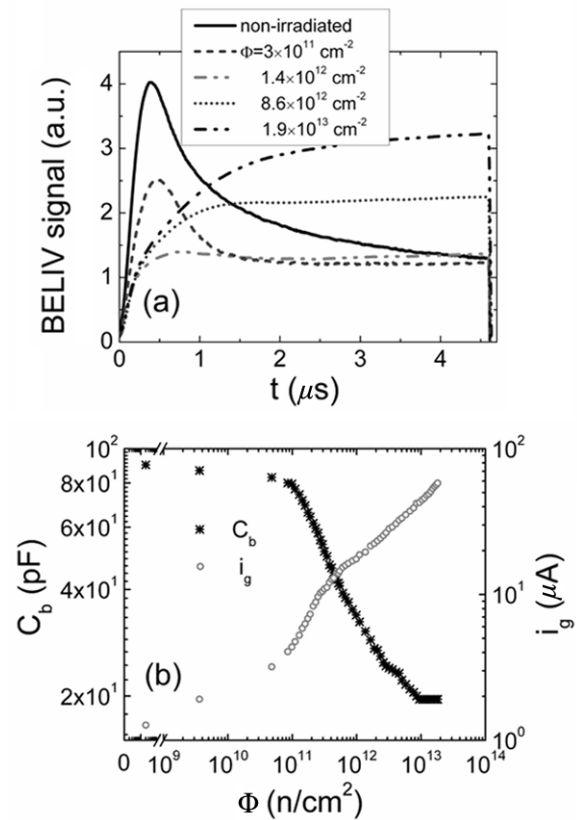


Fig. 1. BELIV transients (a) and variations of barrier capacitance and generation current (b) measured *in situ* on Si pin diodes during spallator neutron irradiation.

with enhancement of fluence and reaches its geometrical value at the fluence $\Phi \geq 10^{13} \text{ cm}^{-2}$. A reduction of barrier capacitance appears due to the carrier capture by radiation defects. Meanwhile, the generation current increases with enhancement of the neutron irradiation fluence. The generation current becomes the dominant component at fluences $\Phi > 10^{12} \text{ cm}^{-2}$.

Spectroscopy and identification of the prevailing radiation defects under neutron fluences above 10^{14} cm^{-2} have been performed after irradiation by temperature scans. This range of fluences is important to predict operational characteristics of the future detectors for the high luminosity colliders.

An enhancement of the generation current component (determined by traps of certain activation energy) in BELIV transients is observed when the duration of the LIV pulse is close to the carrier thermo-emission lifetime. This peculiarity has been employed for the *ex situ* measurements of the temperature dependent variations of BELIV transients by varying duration of the LIV pulses. The obtained temperature dependent variations of BELIV transients for the fixed irradiation fluence (a) and extracted generation current (b) for diodes irradiated with different fluences are presented in Fig. 2. The activation energy values of 0.18 ± 0.01 , 0.26 ± 0.02 , and 0.40 ± 0.02 eV have been evaluated for the dominant traps, and these traps are ascribed to the vacancy-oxygen (VO) and divacancy (V_2) type defects, respectively, using literature data of deep level signatures [10]. It has been unveiled that the higher irradiation fluence in the deeper levels prevails in the formation of the generation current.

The temperature dependent MW-PC transients have been additionally examined on the reactor neutrons irradiated n-type Si wafer samples in the fluence range of about 10^{14} cm^{-2} . The carrier recombination and trapping lifetime values as a function of the inverse thermal energy (extracted from the measured MW-PC transients) are plotted in Fig. 3, as obtained for the samples irradiated with the fluence of 10^{14} cm^{-2} . Carrier decay transients for the as-irradiated samples appear to be the single-exponential waveform. However, these transients are transformed into the two-componential decays after anneals.

The two-componential decay manifests that the relaxation process of excess carrier density is governed by a two-centre system, one of which has close values of the capture cross-section for electrons and holes, while another defect traps only single-type carriers. Conventionally such a process is described by the instantaneous trapping lifetime [11]:

$$\tau_{tr} = \tau_R [1 + M N_M / (N_M + \Delta n)^2]. \quad (2)$$

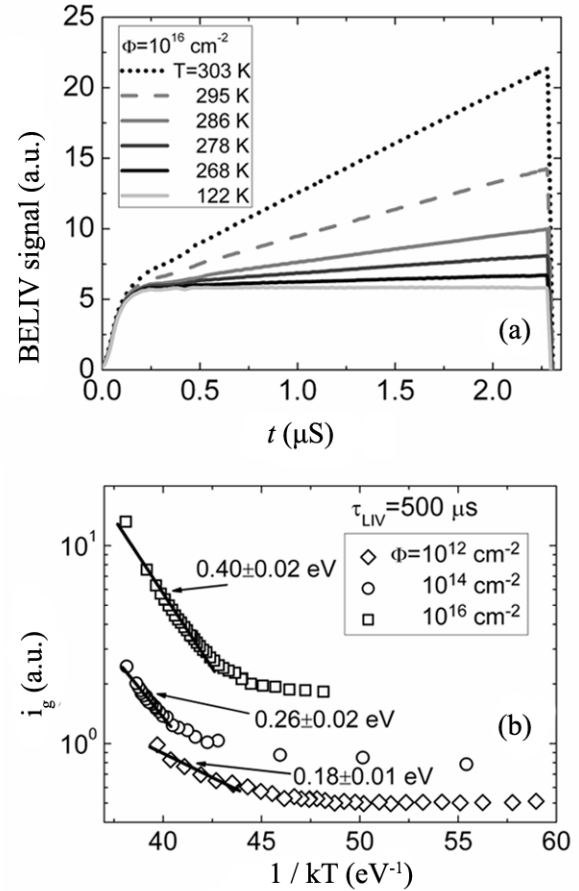


Fig. 2. (a) Temperature dependent BELIV transients measured on a pin diode irradiated by reactor neutrons at the fluence $\Phi = 10^{16} \text{ cm}^{-2}$. (b) Generation current variations versus inverse temperature measured on pin diodes irradiated by reactor neutrons of different fluences.

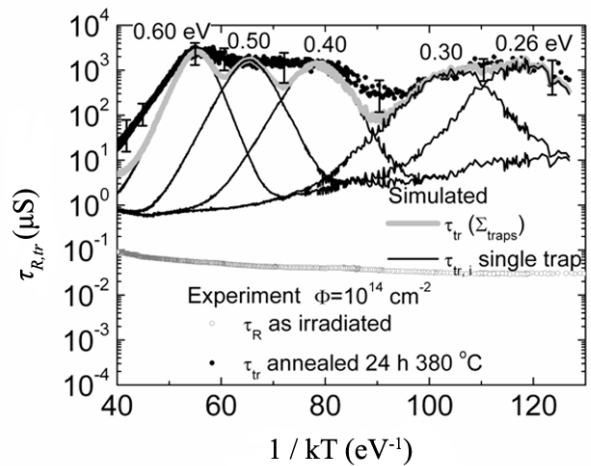


Fig. 3. Temperature dependent carrier recombination τ_R and trapping τ_{tr} lifetime variations in reactor neutrons as irradiated at fluences $\Phi = 10^{14} \text{ cm}^{-2}$ and annealed Si wafer samples.

Here, τ_R is a recombination lifetime described by the Shockley-Read-Hall (S-R-H) model with the well-known dependencies on the excess carrier density Δn and temperature T . The single-type carrier trapping is determined by the concentration M of such type defect and the effective density of states reduced by the trap activation factor $N_M = N_{C,V} \exp(-\Delta E_M/kT)$. Spectroscopy by using the trapping effect is namely based on temperature dependent changes of the carrier lifetime through variations of the effective density of states (i. e. $N_M(T)$). Hereby, trapping increases during the relaxation process of Δn , since the excess carrier density falls down, and the trapping effect appears as a long-tail component within the MW-PC transients at relatively low excitation intensity. Also, excess carrier density $\Delta n = \alpha(T)I_{\text{ex}}$ decreases with temperature due to variation of the absorption coefficient $\alpha(T)$ at excitation wavelength λ with the surface excitation quanta flow of I_{ex} and $\alpha(T) = \alpha(T = 300\text{K}) (T/300\text{K})^{4.25}$ at $\lambda = 1062$ nm if the excitation light intensity is kept invariant. It can be deduced from Eq. (2) that the instantaneous trapping lifetime depends on temperature as $\tau_{\text{tr}}(\Delta E_M, T) \sim \exp(-\Delta E_M/kT)$ for $\Delta n \geq N_M$. This trapping lifetime dependence becomes $\tau_{\text{tr}}(\Delta E_M, T) \sim \exp(\Delta E_M/kT)$ for $\Delta n < N_M$. This yields the formation of a peak in the lifetime $\tau_{\text{tr}}(\Delta E_M, T)$ temperature scan, as the density of trapped carriers is varied with temperature.

This formation of the trapping lifetime peaks within the temperature scan can serve as the indication of the transforms of radiation defects. There a system of the simultaneously acting carrier trapping τ_{tr} and recombination τ_R centres is considered. The deep traps act as the recombination defects, while carriers are temporary captured on levels which act as the trapping (generation current) centres. The competition of these centres determines the carrier decay flows and the current components in diode structures. The carrier lifetime (τ_R as well as τ_{tr}) dependences on the inverse thermal energy ($1/kT$) have been employed for evaluation of activation energy of radiation defects. The trapping centres with the activation energy values of $E_{\text{tr}1} = 0.60 \pm 0.03$, $E_{\text{tr}2} = 0.50 \pm 0.02$, $E_{\text{tr}3} = 0.40 \pm 0.02$, $E_{\text{tr}4} = 0.30 \pm 0.02$, and $E_{\text{tr}5} = 0.26 \pm 0.02$ eV should be employed to fit the experimental trapping lifetime changes within the temperature scan for the diode irradiated with neutron fluence $\Phi = 10^{14}$ cm⁻² and annealed at 380 °C. Here, a pedestal of the simulated peaks is the variation of the measured recombination lifetime. In Fig. 3, the symbols represent the experimental changes of carrier lifetime values, while the simulated trapping lifetime peaks attributed to a definite level with the characteristic activation energy are shown by lines. There, the grey curve represents the simulated sum over all the acting trapping cen-

tres. The overlap of the trapping ascribed peaks in the lifetime temperature scans ($\tau_{\text{tr}}-1/kT$) can be noticed in Fig. 3. De-convolution of the $\tau_{\text{tr}}-1/kT$ bands enabled us to distinguish the centres with the activation energy values of $E_{\text{tr}1} = 0.60 \pm 0.03$, $E_{\text{tr}2} = 0.50 \pm 0.02$, and $E_{\text{tr}4} = 0.30 \pm 0.02$ eV ascribed in literature to the radiation clusters [10] and $E_{\text{tr}3} = 0.40 \pm 0.02$ and $E_{\text{tr}5} = 0.26 \pm 0.02$ eV [1, 2] commonly attributed to the single- and double-charged divacancy (V_2^{-0} , $V_2^{-/}$), respectively. It can be deduced by comparing the extracted deep level activation energy values that the divacancies appear as the most efficient carrier trapping centres, which determine the generation current in the diode. Additionally, the thermal treatment activates a rich spectrum of traps. In the as-irradiated material, the cluster defects are the dominant recombination centres, while these defects can act as the single-type carrier capture levels with large cross-sections under anneal induced defect transforms.

The unveiled rich spectrum of traps is also a reason for the reduction of the barrier capacitance of rather heavily neutron irradiated diodes made of the large resistivity Si material. Conductivity carriers supplied by the shallow dopants of a rather small density are rapidly captured by radiation defects with concentrations considerably exceeding that of doping. Then, the base region of a diode becomes a fully depleted layer to support the U_{bi} barrier, and it acts as an extremely large resistivity structure. As a result, the generation current dominates in such a heavily irradiated detector.

4. Summary

A combined study of temperature dependent generation current and carrier recombination and trapping components within MW-PC transients is an effective tool for the *in situ* and *ex situ* spectroscopy of radiation defects. These combined techniques are preferential when standard methods such as DLTS are non-applicable due to a large density of traps which significantly exceeds that of doping. It has been revealed that the barrier capacitance charging current component decreases while the generation current component increases within the pulsed current transient generated by linearly increasing voltage applied on the diode, with enhancement of spallator neutron fluence. An analysis of temperature dependent generation current and carrier lifetime allowed us to evaluate the activation energy of carrier recombination and trapping centres. The trapping centres with the activation energy values of $E_{\text{tr}1} = 0.60 \pm 0.03$, $E_{\text{tr}2} = 0.50 \pm 0.02$, and $E_{\text{tr}4} = 0.30 \pm 0.02$ eV, ascribed to the radiation clusters, and $E_{\text{tr}3} = 0.40 \pm 0.02$ and $E_{\text{tr}5} = 0.26 \pm 0.02$ eV, attributed

to the single- and double-charged divacancy ($V_2^{-/0}$, $V_2^{+/}$), have been distinguished by the analysis of the MW-PC trapping lifetime. The activation energy values of 0.18 ± 0.01 , 0.26 ± 0.02 , and 0.40 ± 0.02 eV of the prevailing carrier generation centres have been evaluated by the BELIV technique. These traps are ascribed to the vacancy-oxygen (VO) and divacancy (V_2) defects, respectively.

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RADIACINIŲ GAUDYKLIŲ SILICYJE SPEKTROSKOPIJA PAGAL FOTOLAIDUMO IR GENERACINĖS SROVĖS TEMPERATŪRINIUS KITIMUS

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Santrauka

Darbe ištirti Čochralskio būdu (MCZ) magnetiniame lauke išauginto ir neutronais apšvitinto $\Phi \cong 10^{14} \text{ cm}^{-2}$ įtėkiu n-laidumo Si padėklai bei šios Si medžiagos pagrindu pagaminti pin diodai. Tyrimai vykdyti pasitelkiant barjerinės talpos elektrinio srovių ir mikrobangomis zondojuojamo fotolaidumo kinetikų matavimo metodus. Identifikuoti *in situ* barjerinės talpos ir generacinės

srovės kitimus nulėmusieji radiaciniai defektai, sukurti Si diodiniuose dariniuose apšvitintus spalatoriaus neutronais. Nustatyta, kad barjerinės talpos elektrinio srovės komponentė mažėja, o generacinės srovės nulemta komponentė auga didėjant neutronų įtėkiui. Analizuojant generacinės srovės ir krūvininkų gyvavimo trukmės temperatūrinius kitimus buvo įvertintos dominuojančių gaudyklių aktyvacijos energijos.